

2.

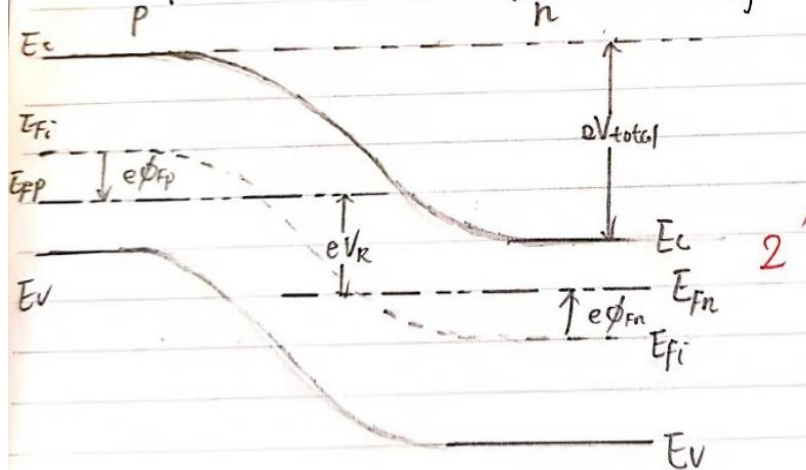
$$V_{bi} = \frac{kT}{e} \ln \left(\frac{N_d N_a}{n_i^2} \right) = 0.718 \text{ V}$$

$$W = \left\{ \frac{2\epsilon_s (V_{bi} + V_R)}{e} \left[\frac{N_a + N_d}{N_a N_d} \right] \right\}^{\frac{1}{2}} = 1.576 \times 10^{-4} \text{ cm} = 1.576 \mu\text{m}$$

$$|E_{max}| = \left| \frac{2(V_{bi} + V_R)}{W} \right| = 1.11 \times 10^5 \text{ V/cm}$$

$$x_n = \left\{ \frac{2\epsilon_s (V_{bi} + V_R)}{e} \left[\frac{N_a}{N_d} \right] \left[\frac{1}{N_a + N_d} \right] \right\}^{\frac{1}{2}} = 1.43 \times 10^{-4} \text{ cm} = 1.43 \mu\text{m}$$

$$x_p = \left\{ \frac{2\epsilon_s (V_{bi} + V_R)}{e} \left[\frac{N_d}{N_a} \right] \left[\frac{1}{N_a + N_d} \right] \right\}^{\frac{1}{2}} = 1.43 \times 10^{-5} \text{ cm} = 0.143 \mu\text{m}$$



1. ① Large amount of Si on earth, low cost 2

② Form high quality SiO_2 and good interface 2

(Any reasonable answer can get credits)